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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of

Applicants : Chandra V. Mouli and Ceredig Roberts
Serial No. : 09/648,044
Filed : August 25, 2000
Confrm. No. : 6800
Title : METHOD AND DEVICE TO REDUCE GATE-INDUCED DRAIN
LEAKAGE (GIDL) CURRENT IN THIN GATE OXIDE MOSFETs
Docket No. : MIO 0054 PA
Examiner : O. Nadav
Art Unit : 2811

MAIL STOP AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

EFS WEB ELECTRONIC SUBMISSION
January 16, 2007

**/William A. Jividen/
Reg. No. 42,695**

Sir:

AMENDMENT

This paper is being filed in response to the Office Action mailed October 20, 2006.
Reconsideration is respectfully requested in light of the amendments and remarks below.